

μ GISAXS and μ XRR experimental set-up for thin film characterization

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Introduction

In recent years, a grazing incidence small-angle x-ray scattering (GISAXS) technique has become widely used for the characterization of surface or buried structures of thin films. From the GISAXS pattern, we are able to determine the size, shape, size distribution of the particles and/or the information of the nm ordered structures. In addition, X-ray reflectivity (XRR) measurement gives us information on thin films such as a film thickness, film density, surface roughness and interface roughness. A combination of these techniques is preferable for the understanding of thin film structures. Both GISAXS and XRR measurements are carried out under the grazing incidence configuration, which is around the total external reflection angle. So the footprint of the incident beam becomes large, up to a few cm under the conventional experimental condition. That means we can only get average information on the film parameters and that need a uniform and large sample. If we use the X-ray micro-beam as an incident beam, the footprint along the x-ray beam becomes small. And it is desirable that two techniques are used for same area with the same experimental set-up. But the combination of μ GISAXS[1] and XRR measurements of the same area has been only recently tried [2].

So, we developed μ GISAXS [3] and μ XRR system for measuring the same small area using X-ray micro-beam.

Experiment

μ GISAXS and μ XRR measurements were carried out on the BL4A at the Photon Factory. The X-ray micro-beam was formed by the Kirkpatrick-Baez focusing system. The size of incident beam was around $5\mu\text{m} \times 5\mu\text{m}$ and the divergence of the incident beam was around 0.2mrad. X-ray energy was 11keV ($\lambda=0.11\text{nm}$). The scattered/reflected x-ray beam was detected using an image-intensified CCD detector (II-CCD) for μ GISAXS and μ XRR. An X-ray path from the sample to the detector about 150cm long was evacuated to reduce air scattering. The present μ GISAXS set-up adopted a specular beam attenuator which was not so thick that it could stop the specularly reflected beam. At the set-up of the μ XRR, we used another set of the specular beam attenuator that had a suitable thickness which enabled transmitted X-rays to be measured within the dynamic range of the II-CCD. Since the exchange of the specular

beam attenuator of μ GISAXS for μ XRR, and vice versa, was easy, we could measure the μ GISAXS and μ XRR at the same area under the same condition.

Results and Discussion

By using this set-up, we measured indium contained oxide film of about 20nm thick evaporated on a Si substrate. The μ XRR measurement was performed by scanning of the incident angles. The X-ray reflectivity curve was calculated by extracting the specular spot region. Fig.1(a) is the obtained μ XRR pattern from this film. The obtained reflectivity curve exhibits a typical interference pattern for the thin film. From this XRR curve, we performed the calculation in order to obtain parameters of the film based on the one layer model. After the μ XRR measurement, by changing the specular beam attenuator and setting the sample to the particular incident angle, we can easily move on the μ GISAXS measurement. Fig1(b) shows a μ GISAXS image taken at 0.30° incident angle.

The combination of μ XRR and μ GISAXS is simply realized by changing the specular beam attenuator optimized for each measurement. Using our system, we could measure the μ GISAXS and μ XRR from the same small area of the thin film.

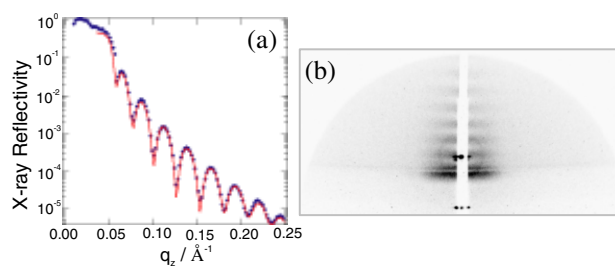


Fig.1 (a) shows μ XRR profile. The blue circles are experimental data and the red line is the calculated one. (b) μ GISAXS image taken at 0.30° incident angle.

References

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